

Films and Crystals: Search for the Perfect Structure

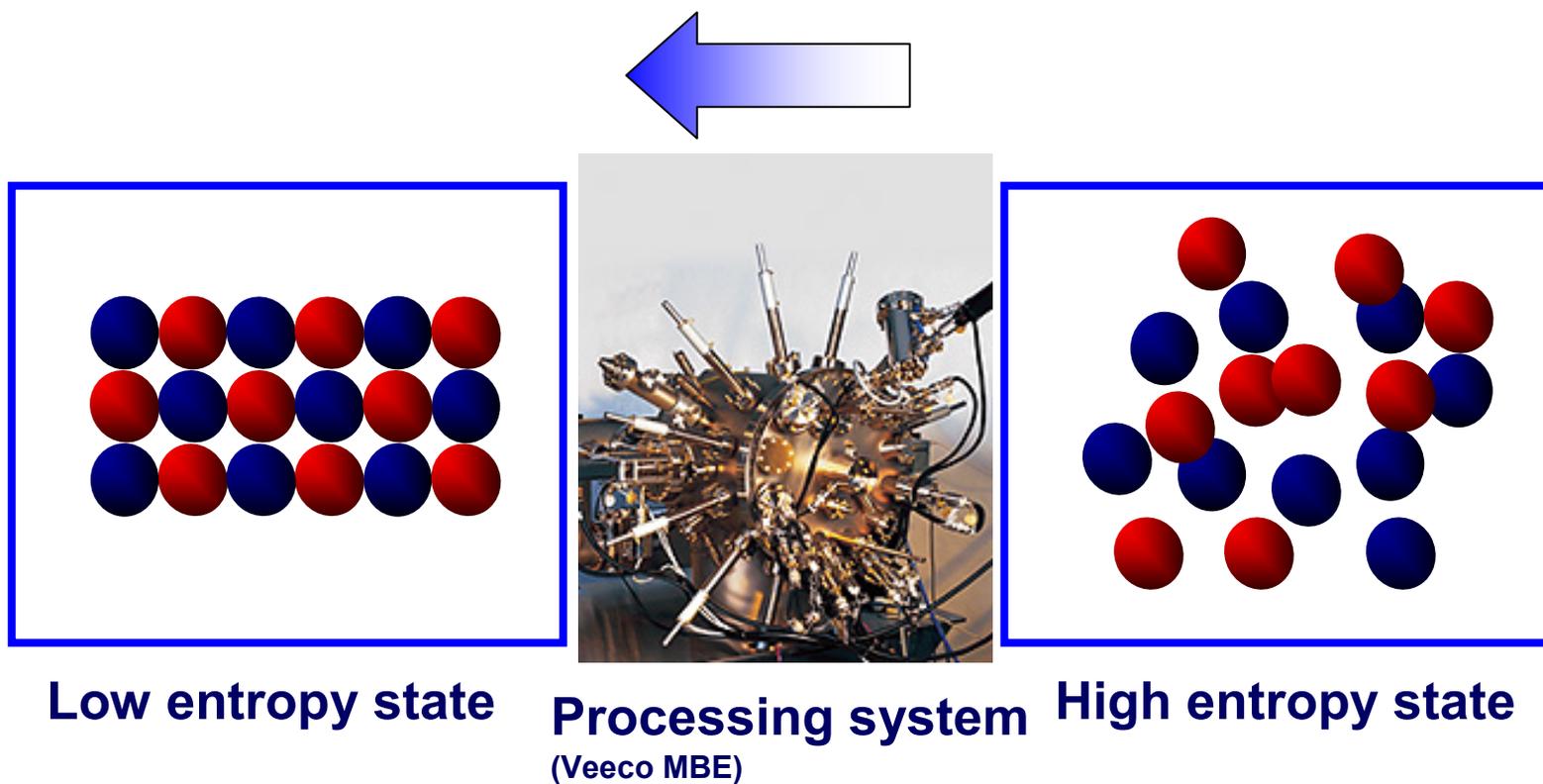
BROOKHAVEN
NATIONAL LABORATORY

Seminar at AMSC, February 1 2007.

Slawa Solovyov

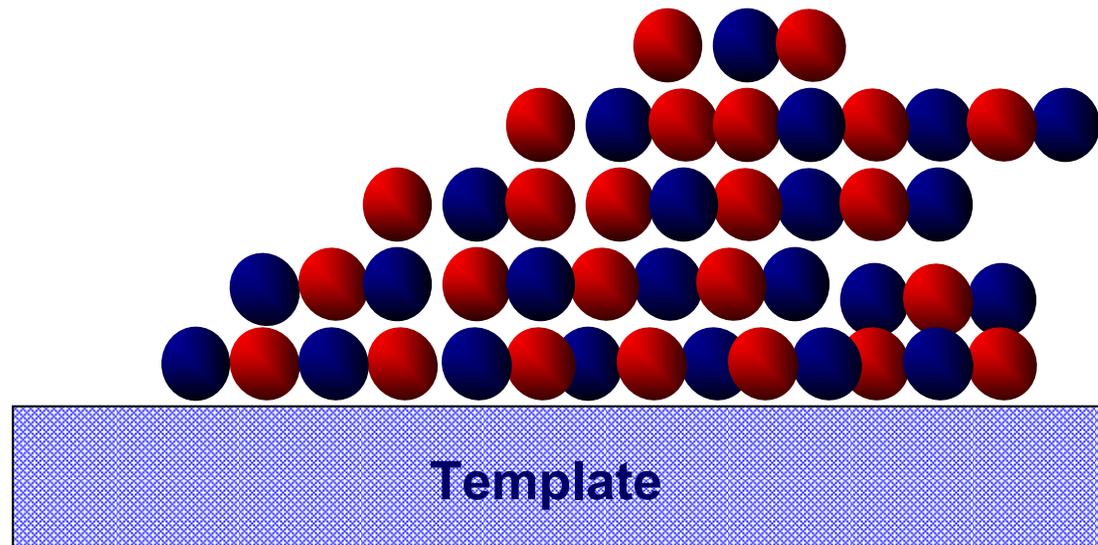
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How we make materials



➤ Material making is a process of local entropy reduction by heating the outside world.

Can we make perfect materials in bulk?

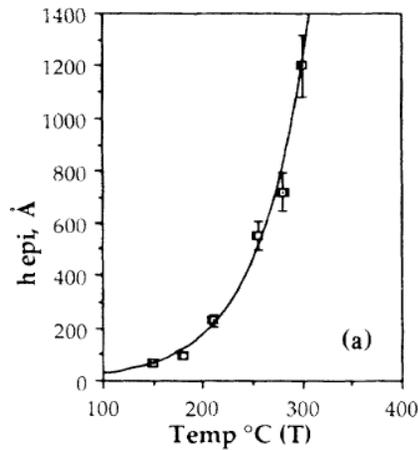


➤ If we wait long enough, can we make 1" thick perfect film?

Case 1: Low-temperature epitaxy of Ge and Si

Si on Si

Ge on Ge



K. A. BRATLAND *et al.*

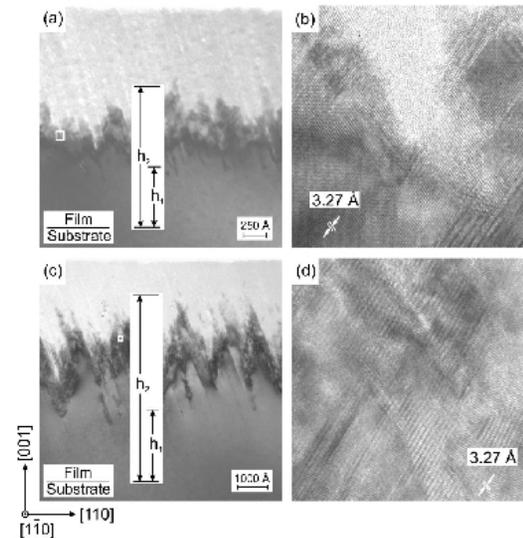
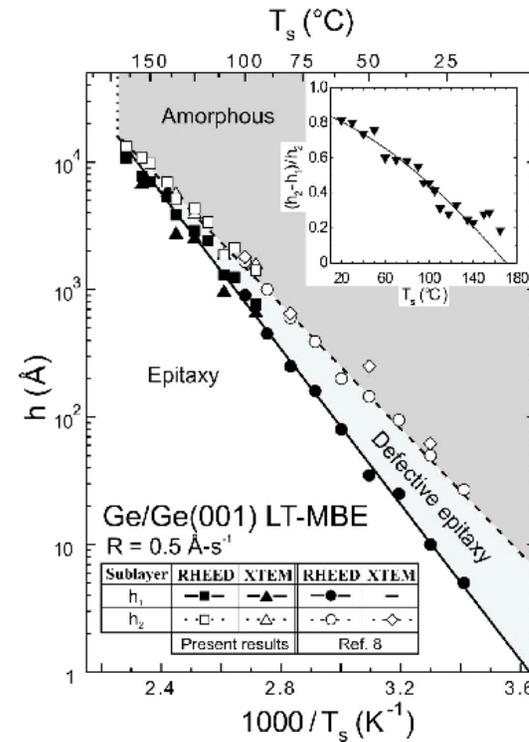


FIG. 2. [110] bright-field zone-axis XTEM micrographs of Ge(001) layers grown by LT-MBE at T_s with $R = 0.5 \text{ \AA s}^{-1}$ to thicknesses h . (a) $T_s = 95 \text{ }^\circ\text{C}$, $h = 2100 \text{ \AA}$ and (c) $T_s = 135 \text{ }^\circ\text{C}$, $h = 6750 \text{ \AA}$. (b) and (d) are HR-XTEM images of the regions outlined by the small open white squares in (a) and (c), respectively.

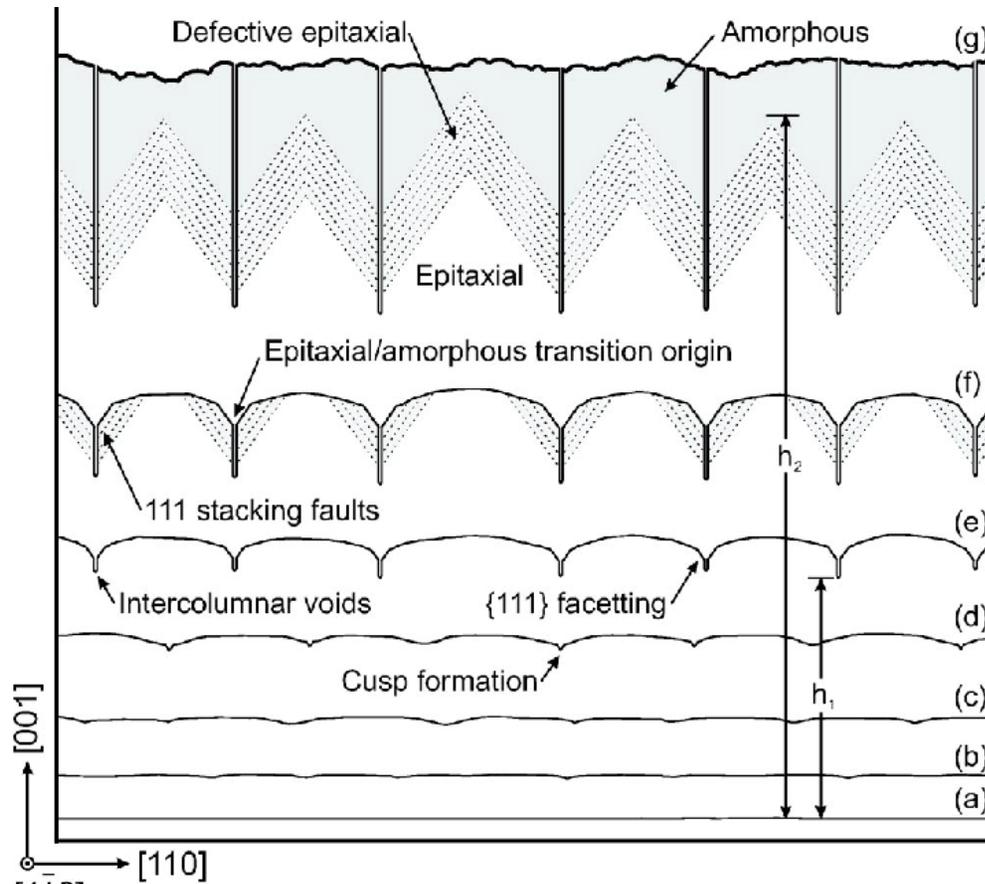
initiated by double-positioning defects on {111} facet planes and microtwins. Examples are shown in Figs. 2(b) and 2(d)

PHYSICAL REVIEW B 67, 125322 (2003)



➤ At given temperature, there is a limit on the epi layer thickness.

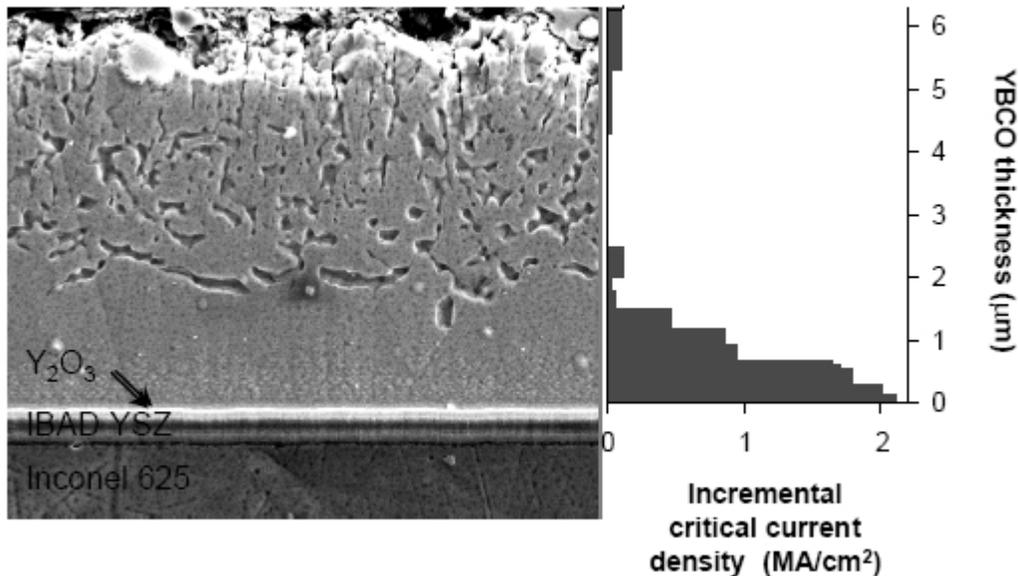
Evolution of Ge epitaxial growth front



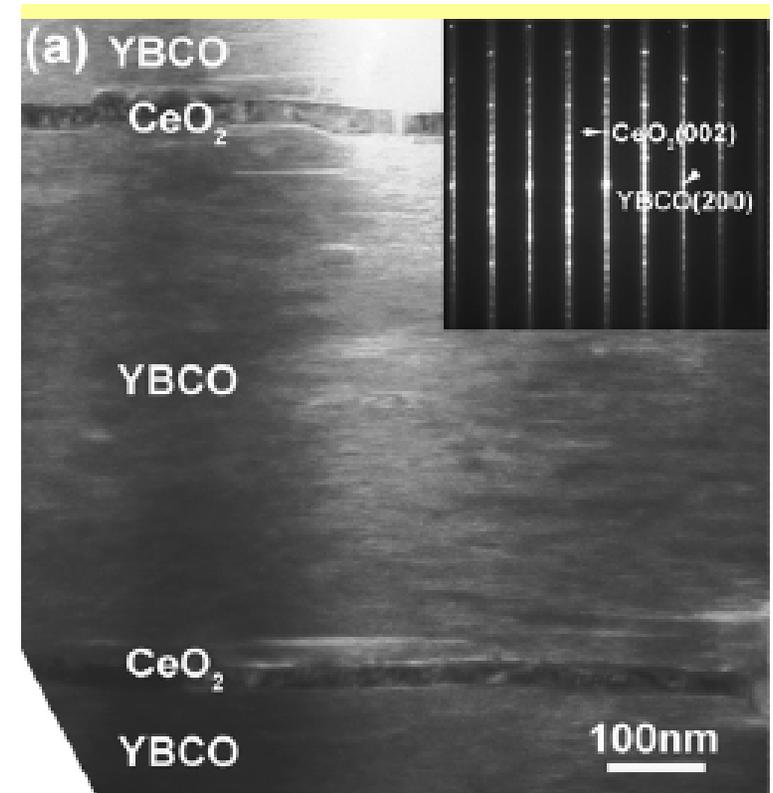
- Defects amplify as the thickness increases resulting in complete loss of epitaxy at the critical thickness.

Case 2: epitaxial growth of thick YBCO film by PLD (Los Alamos result)

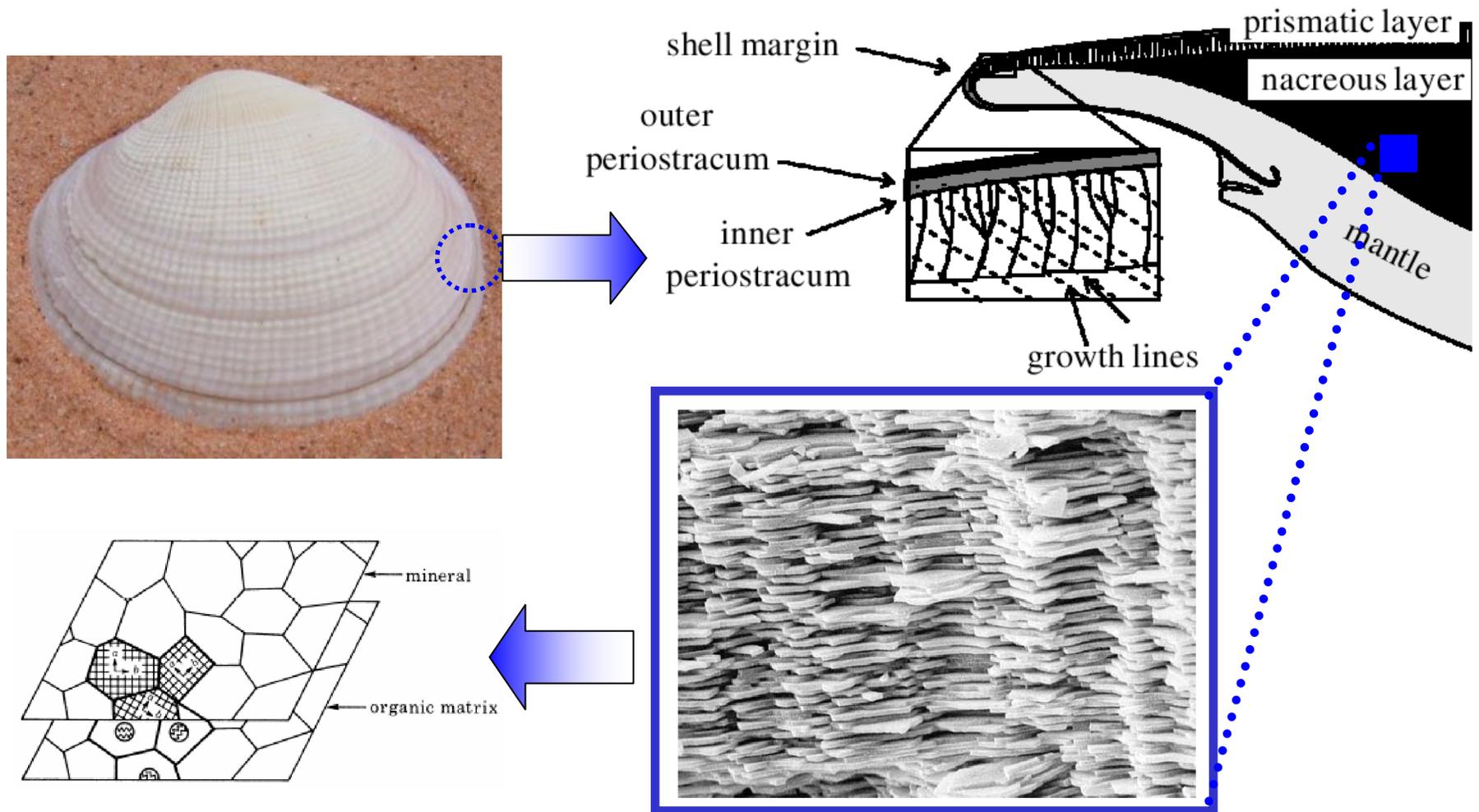
Single-layer



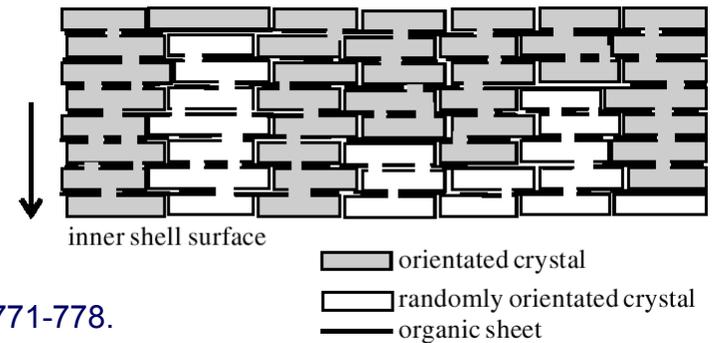
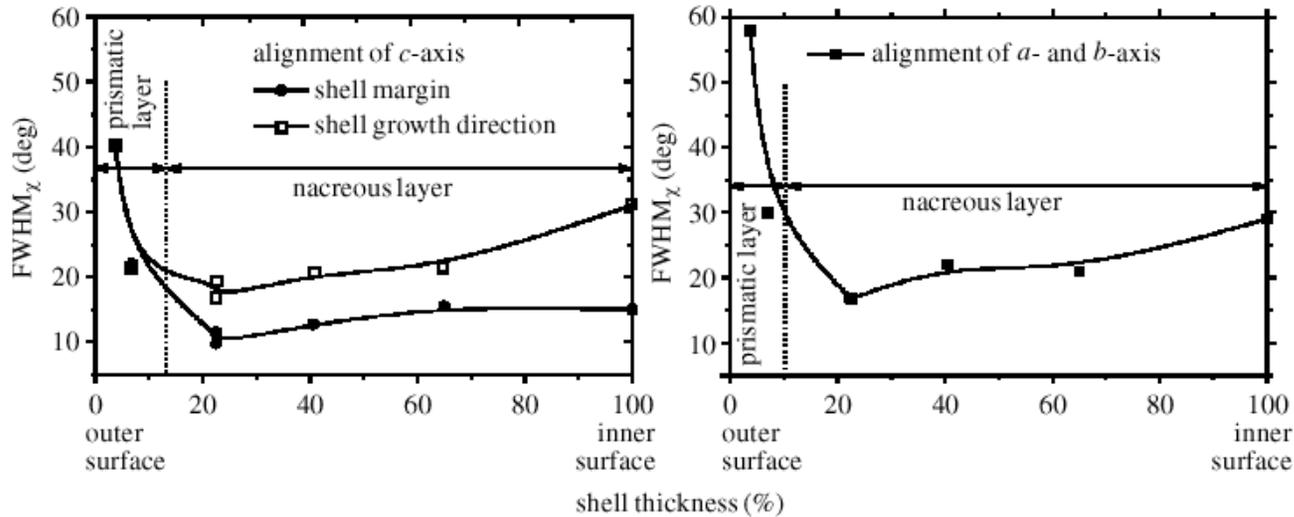
Solution: Multi-layer



Case 3: growth of nacreous (mother of pearl) layer in a clam shell



Degradation of texture in the shell's nacreous layer

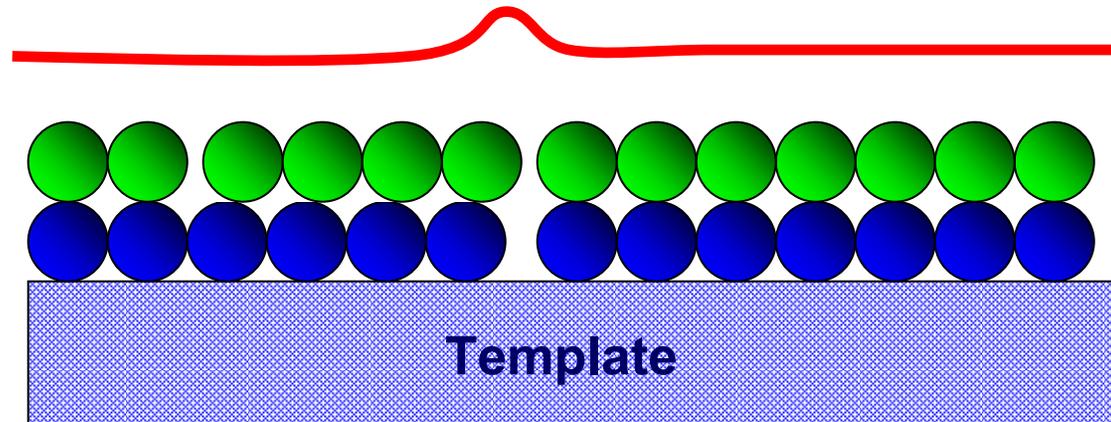


Antonio, G. Checa, Alejandro, Rodríguez-Navarro,
Proceedings of the Royal Society B: Biological Sciences, vol. **268** (2001), pp. 771-778.

➤ Defect accumulation leads to texture degradation of the nacreous layer

Why defects accumulate?

We are paying price for making materials from atoms.

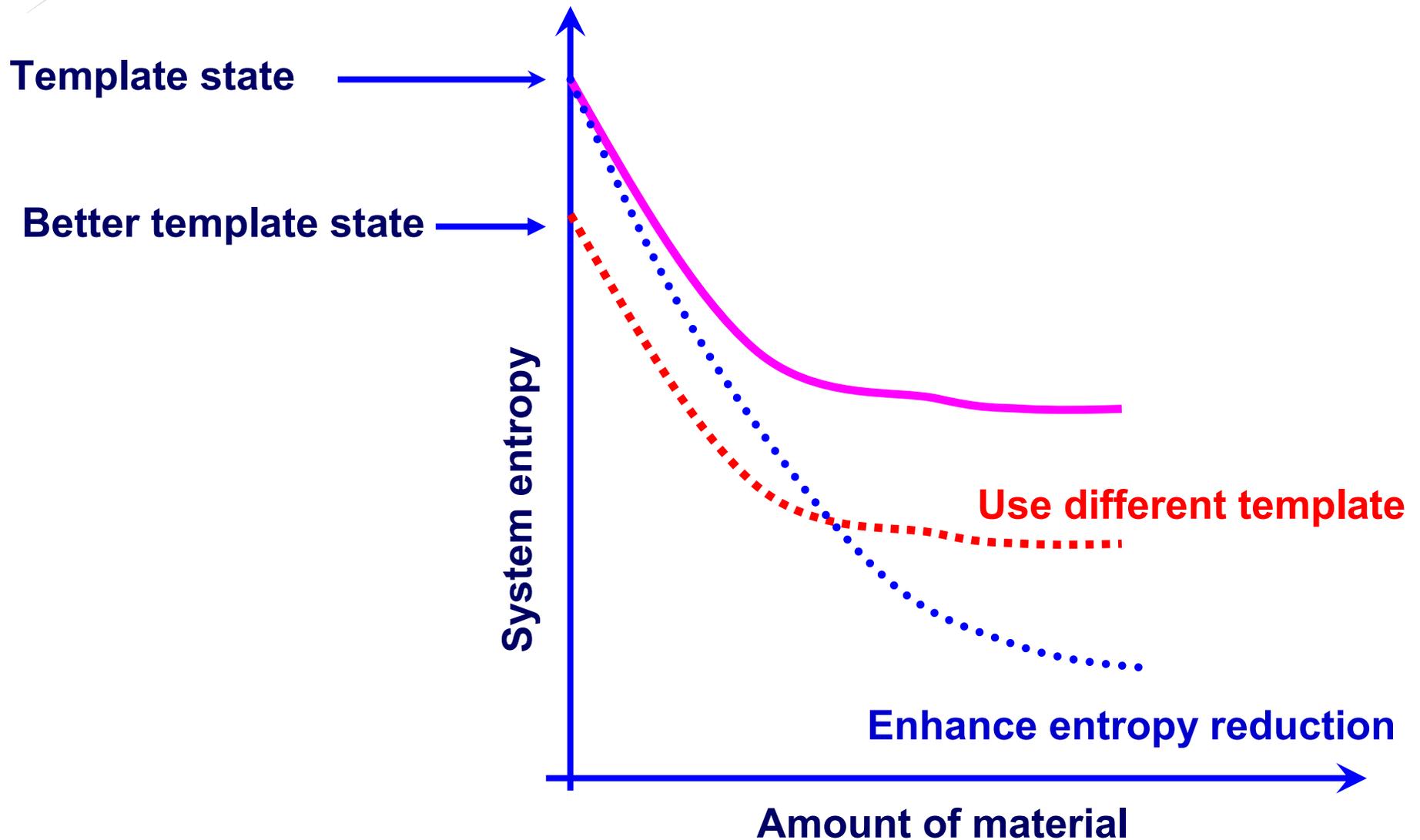


Surface term σ

Volume term σ
 $\mu = \kappa T \ln(P/P_e)$

- Homoepitaxy is sensitive to high-frequency fluctuation of the attraction potential.
- Heteroepitaxy integrates the potential reducing effects of high-frequency harmonics.

What can we do to make material more perfect?

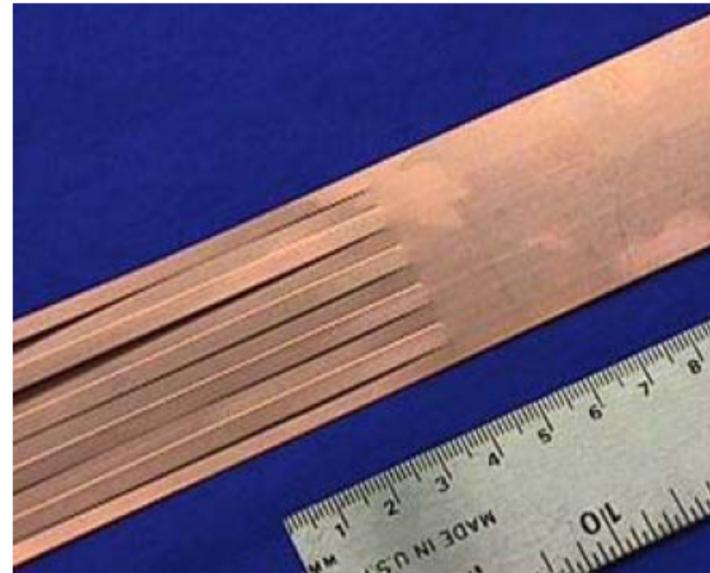


Template factor: two very different substrates

Good, but expensive: SrTiO_3



Not so good, but cheap:
 CeO_2 buffered tape.

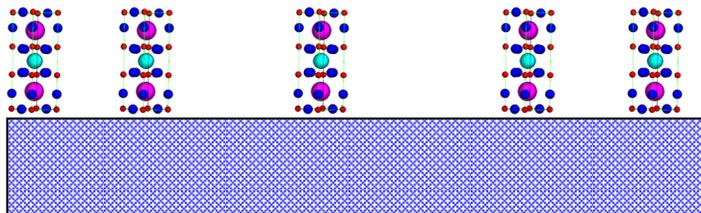
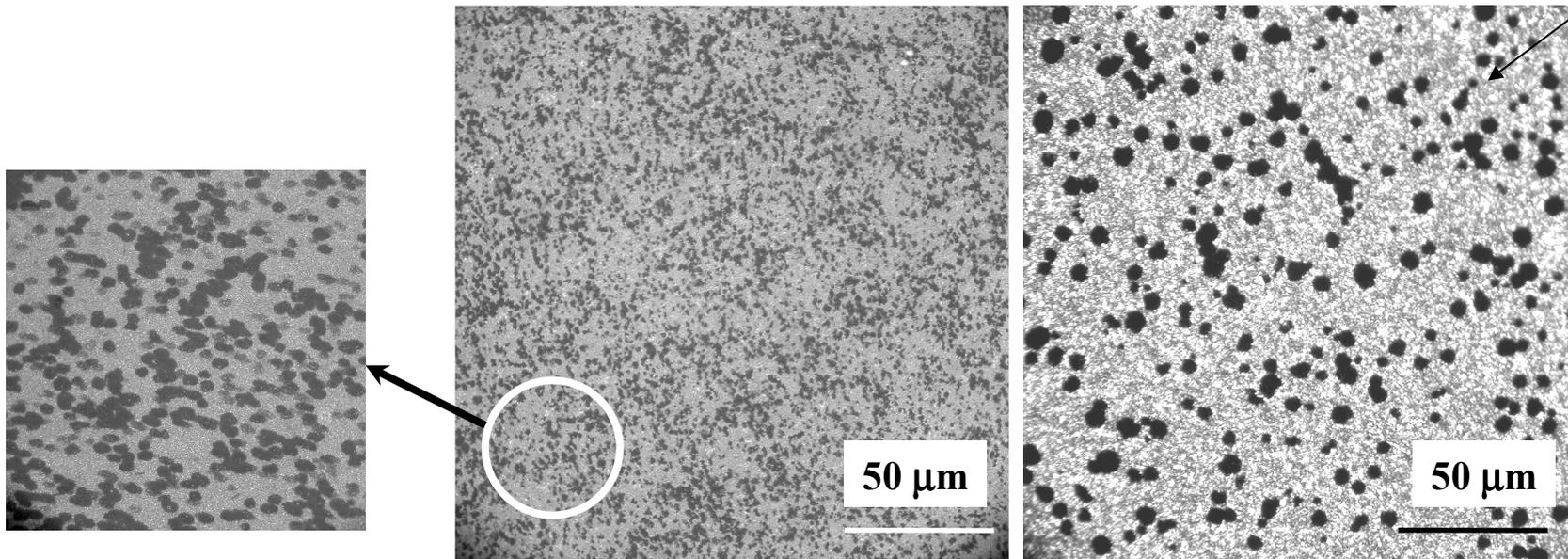


Nucleation efficiency of these two very different templates

Good, but expensive: SrTiO_3

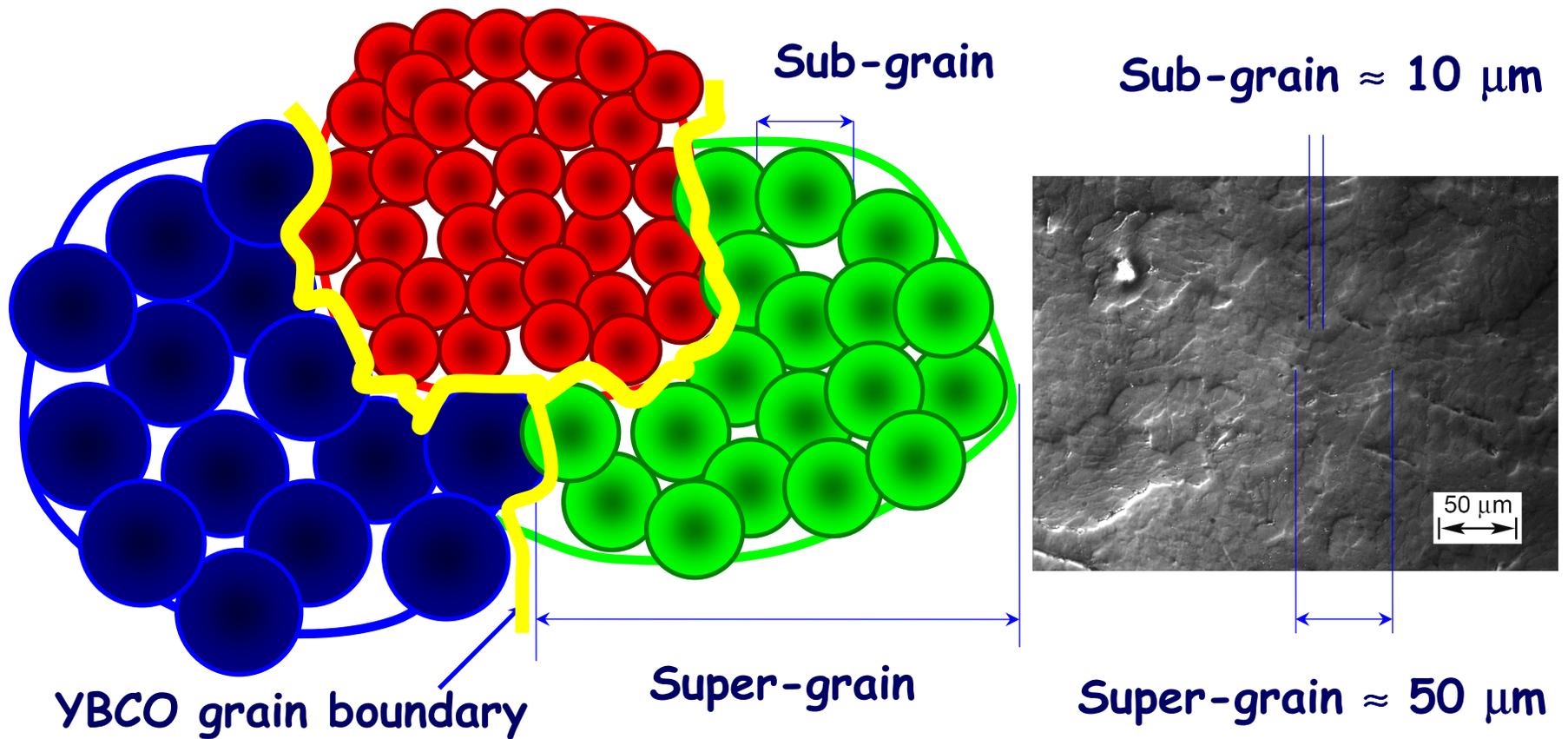
Not so good, but cheap:
 CeO_2 buffered tape.

YBCO



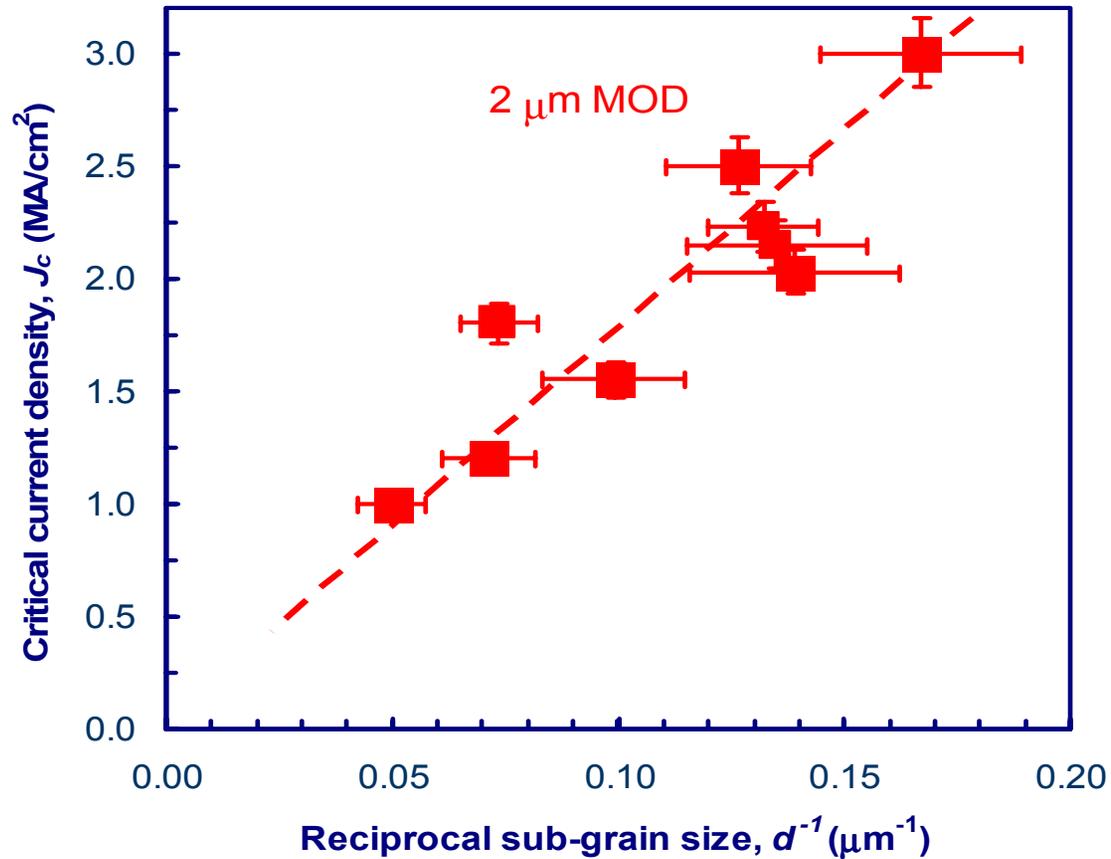
What makes “good” YBCO layer?

Complete YBCO layer



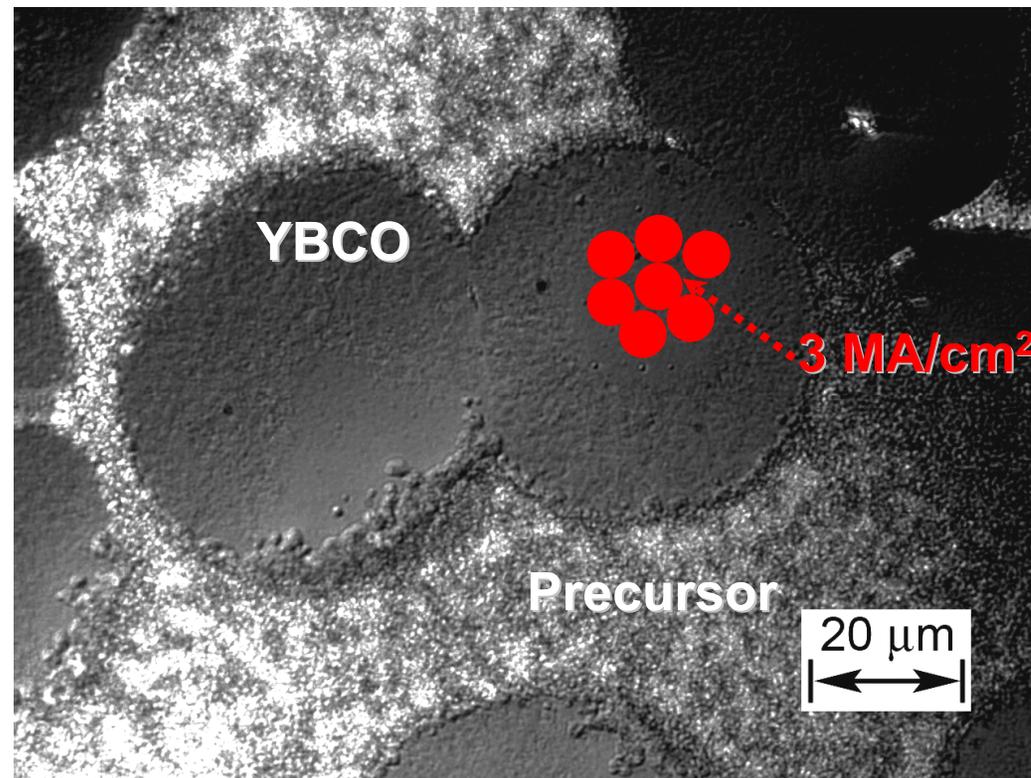
➤ Small sub-grains make good YBCO layer!

Sub-grain size effect on J_c



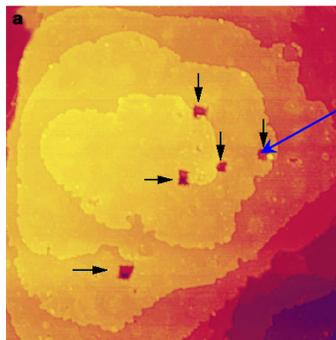
➤ J_c is inversely proportional to the sub-grain size!

Why small grains make good material? or Why large grains make bad material?

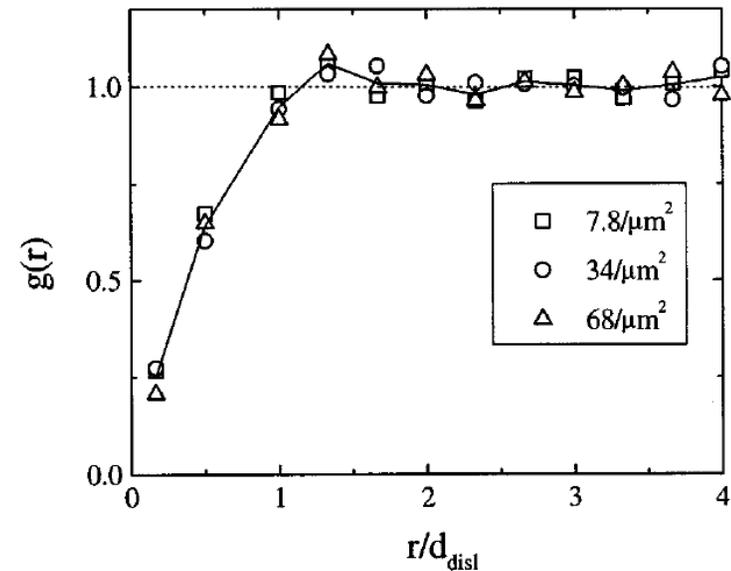
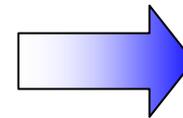
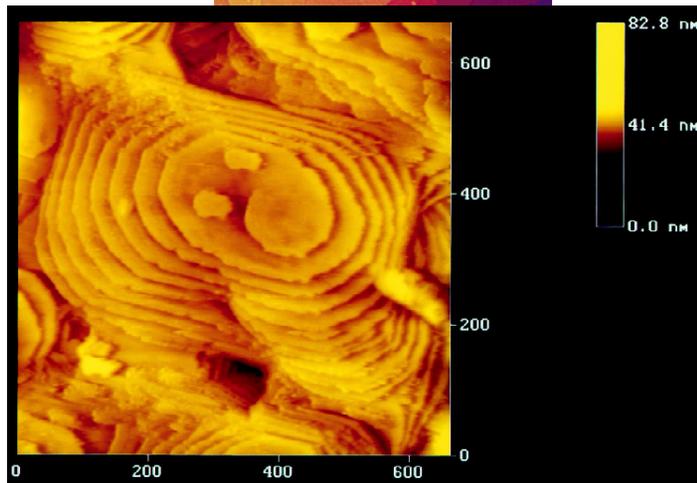


- Structure degrades when the nuclei expand laterally.

Accumulation of dislocations in expanding YBCO island during PLD deposition



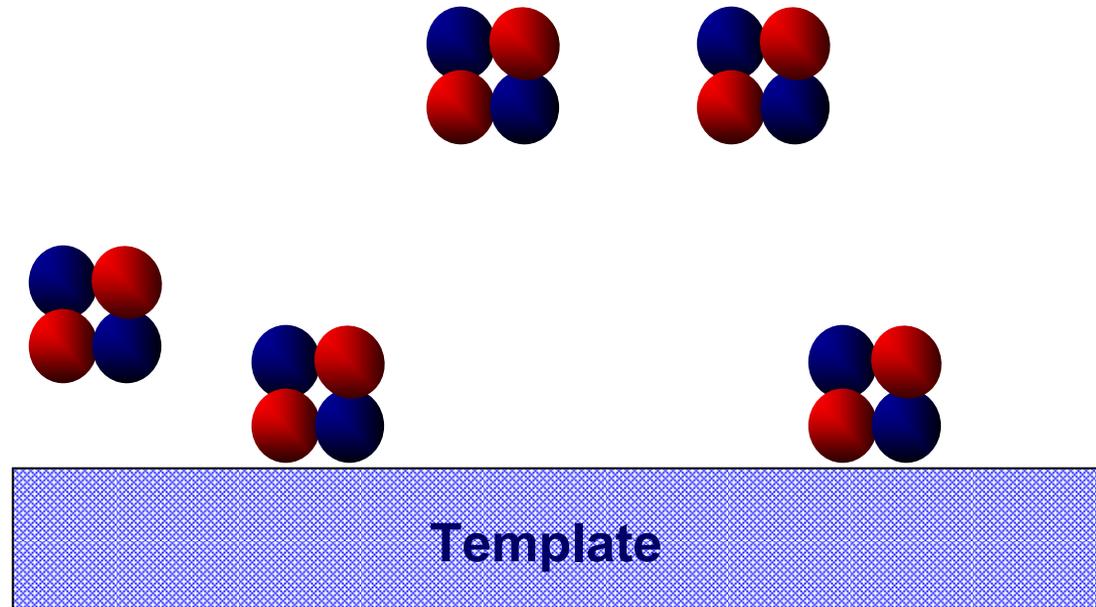
Dislocations revealed by etching



B. Dam, J. M. Huijbregtse, F. C. Klaassen et al.,
Nature 399 (6735), 439-442 (1999).

➤ These dislocations may be responsible for high-field J_c of these films.

Can nano-technology make a breakthrough?

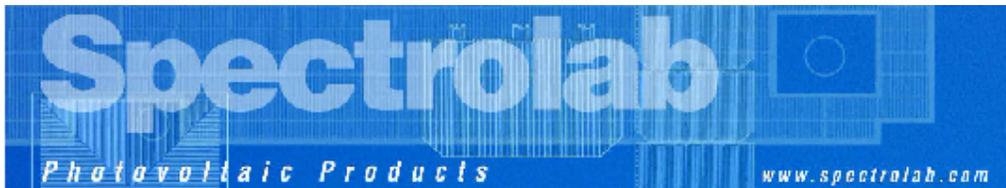


- If we could make material from pre-assembled nano-blocks, we may avoid defect accumulation.

Conclusion

- Very difficult to make bulk perfect.
- Right epitaxial film has a potential to be far more perfect object than a crystal.
- In epitaxial growth right substrate (probably not off-shelf) is 90% of the success, very little we can do with thermal activation.
- Complex materials challenges:
 - No melting point
 - No reversibility
 - Competition from other phases (rich phase diagrams)

Price of perfection and complexity: solar cells



Typical Electrical Parameters

(AM0 (135.3 mW/cm²) 28°C, Bare Cell)

J_{sc}	= 17.05 mA/cm ²
J_{mp}	= 16.30 mA/cm ²
$J_{load\ min\ avg}$	= 16.40 mA/cm ²
V_{oc}	= 2.665 V
V_{mp}	= 2.350 V
V_{load}	= 2.310 V
Cff	= 0.84
Eff _{load}	= 28.0%
Eff _{mp}	= 28.3%

Radiation Degradation

(Fluence 1MeV Electrons/cm²)

Parameters	1x10 ¹⁴	5x10 ¹⁴	1x10 ¹⁵
I_{mp}/I_{mp0}	0.99	0.98	0.96
V_{mp}/V_{mp0}	0.94	0.91	0.89
P_{mp}/P_{mp0}	0.93	0.89	0.86

Thermal Properties

Solar Absorptance= 0.92 (Ceria Doped Microsheet)

Emissance (Normal)= 0.85 (Ceria Doped Microsheet)

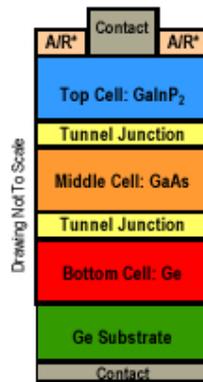
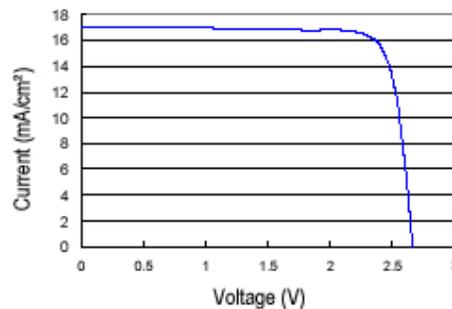
Weight

84 mg/ cm² (Bare) @ 140 μm (5.5 mil) Ge wafer thickness

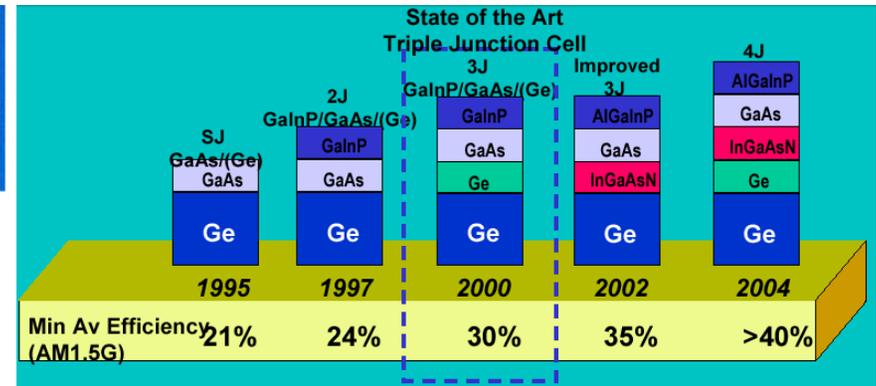
Temperature Coefficients (450 - 750°C)

Typical IV Characteristic

AM0 (135.3 mW/cm²) 28°C, Bare Cell



*A/R: Anti-Reflective Coating



Spectrolab:

Rectangular Dual Junction
GaAs/Ge solar cell:

1.23" x 2.72"

286 mA at 2.05 V

20.02% - above

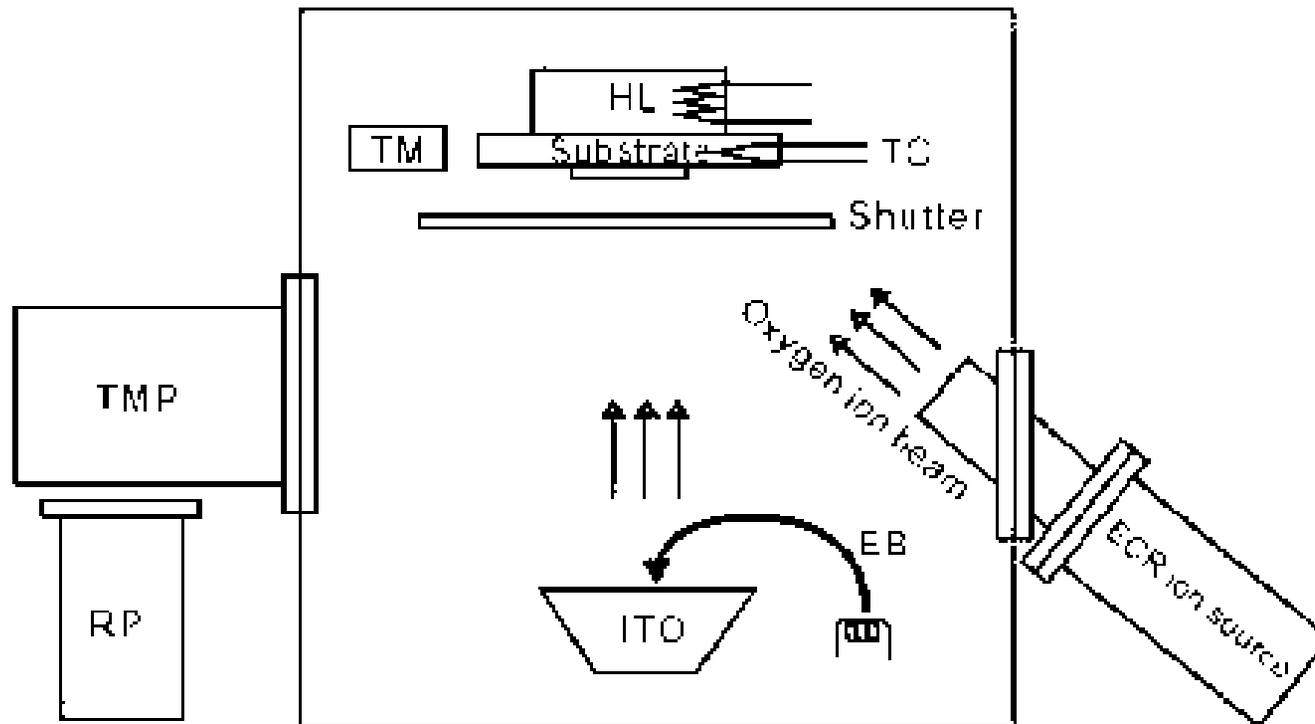
\$630.00 for 50 cells

\$22/Watt

1 kW = \$22,000

Ion beam assistance (IBAD): More effective entropy reduction

Dislocations revealed by etching



➤ IBAD allows use of non-epitaxial substrate.